

## Supporting Information

### Observation of anomalous Hall effect in proximity coupled $\text{Cr}_2\text{Ge}_2\text{Te}_6$ /Graphene heterostructures

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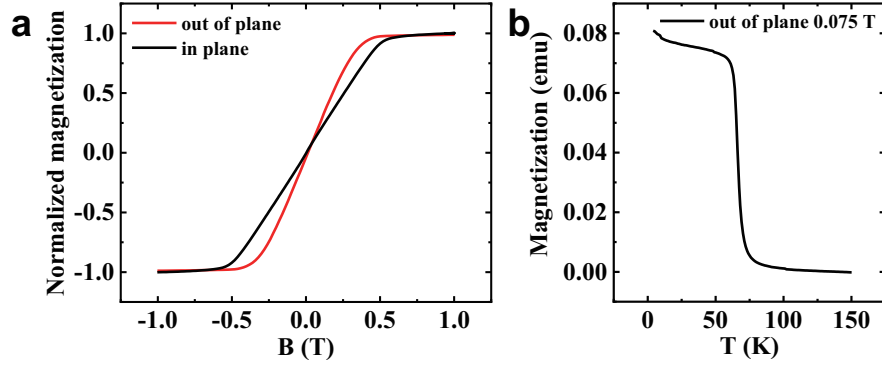


FIG. S1: Magnetization characterizations of a bulk  $\text{Cr}_2\text{Ge}_2\text{Te}_6$  crystal. (a) Magnetization characterization by SQUID at 4K, showing that  $\text{Cr}_2\text{Ge}_2\text{Te}_6$  has an out-of-plane easy axis. (b) Temperature-dependent magnetization characterization under a 0.075 T out-of-plane field, showing  $T_C$  66 K by SQUID at 4 K.

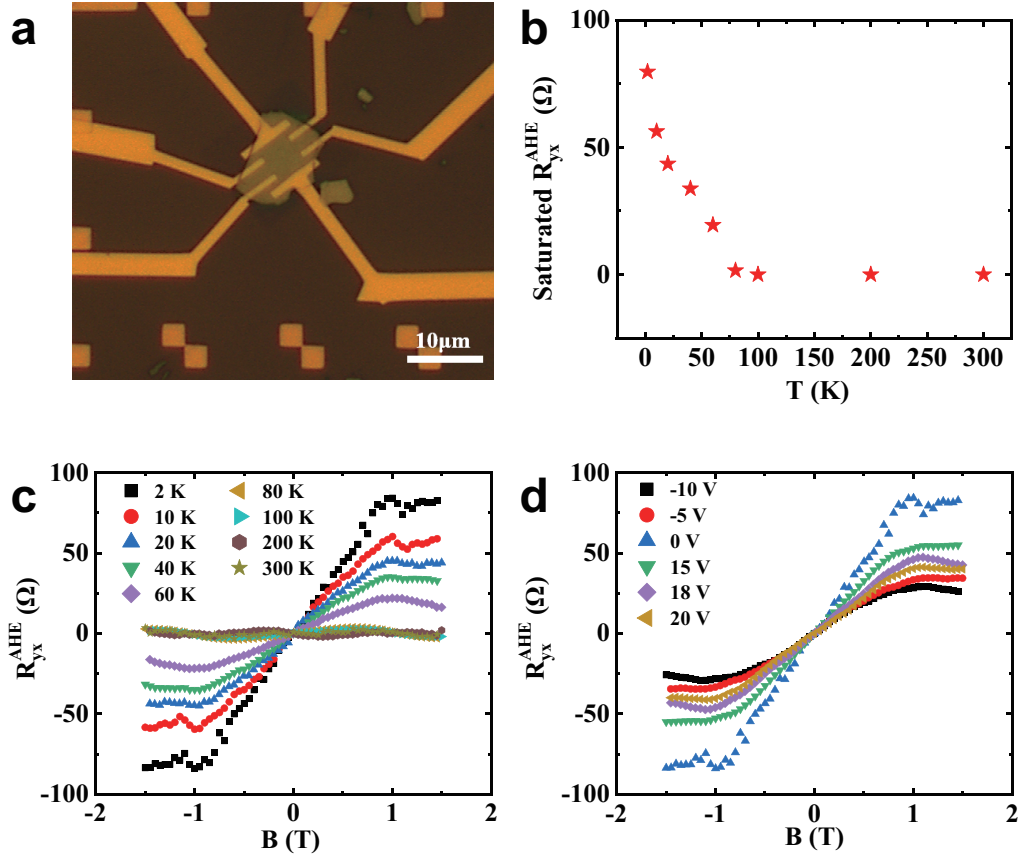


FIG. S2: AHE resistance at different temperatures in device 2. (a) Optical image of the device. (b) The temperature dependence of saturated anomalous Hall resistance of Graphene/CGT. (c) Anomalous Hall resistance of Graphene/CGT measured from 2 K to 300 K. (d) Anomalous Hall resistance of Graphene/CGT at different gate voltages.

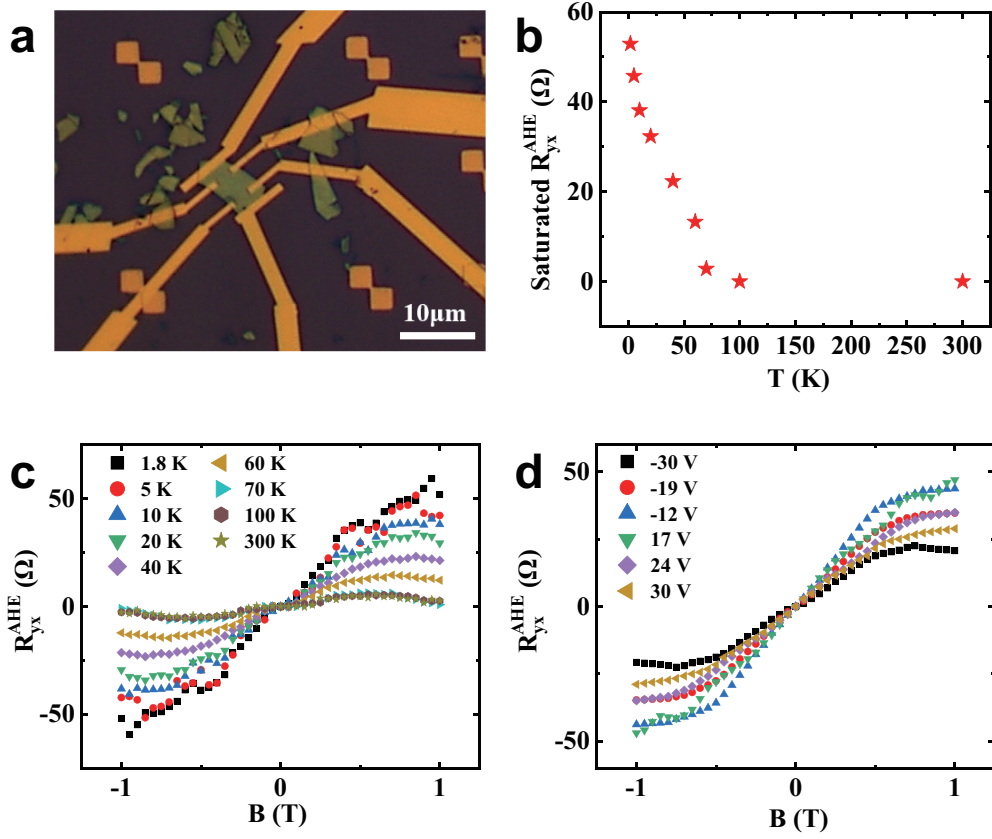


FIG. S3: AHE resistance at different temperatures in device 3. (a) Optical image of the device. (b) The temperature dependence of saturated anomalous Hall resistance of Graphene/CGT. (c) Anomalous Hall resistance of Graphene/CGT measured from 2 K to 300 K. (d) Anomalous Hall resistance of Graphene/CGT at different gate voltages.

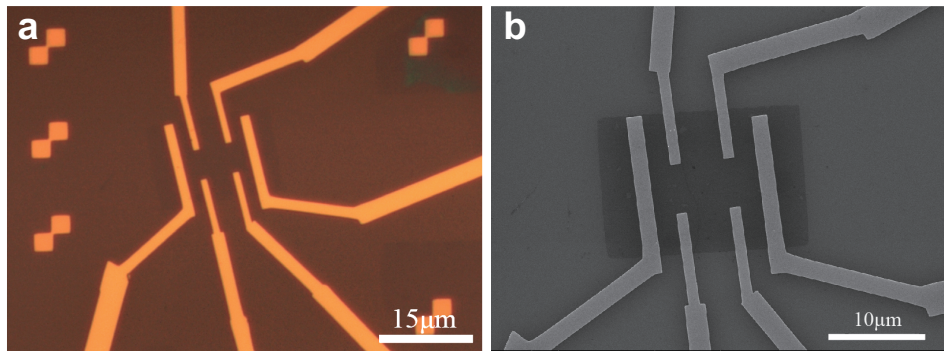


FIG. S4: **The graphene-only device.** (a) The optical image of the graphene-only device. (b) The SEM image of the graphene-only device.

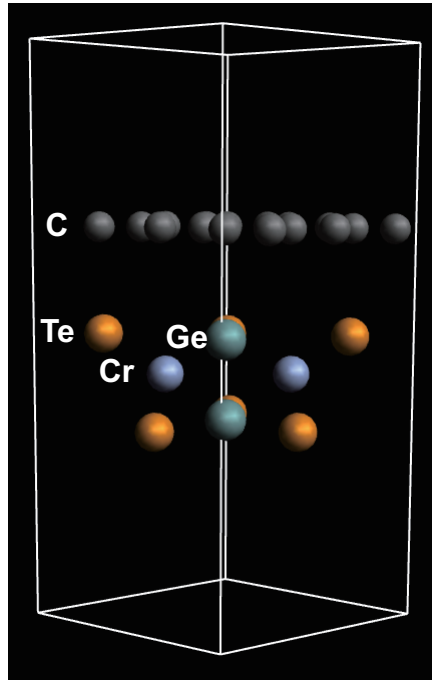


FIG. S5: Atomic configuration for density functional calculations.

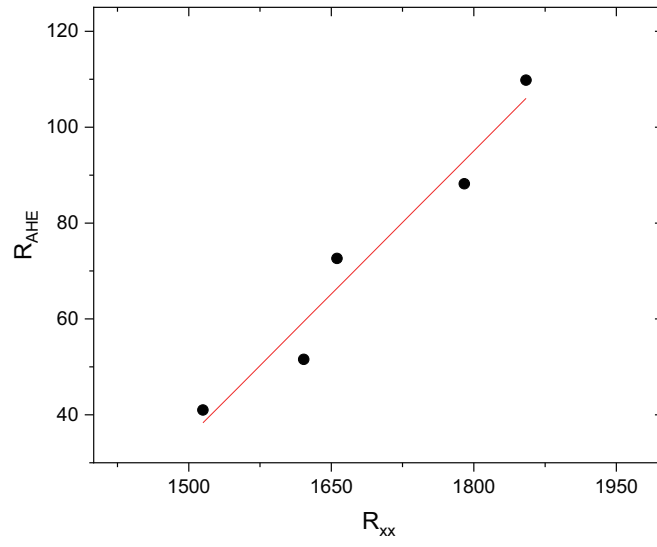


FIG. S6: The relationship between the anomalous Hall resistance  $R_{AHE}$  and the longitudinal resistance  $R_{xx}$ . The red line is the linear fitting to the data.